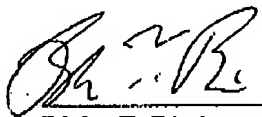


REMARKS

Claims 1 and 8 include the term chemical mechanical polishing for clarity. The specification at paragraph 14, lines 1 to 2 provides a basis for the limitation. In addition, step a of claim 1 now includes the step of determining a critical rotation rate of the article for backmixing. Paragraph 22 provides a basis for this limitation. Finally, step d contains language to improve the correlation to the amended step a. Applicant respectfully submits that these amendments enter no new matter.

Respectfully submitted,

July 22, 2004
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